	Туре	L#	Hits	Search Text	DBs	Time Stamp	Comments	Error Definition	Errors
1	BRS	L1	14012	anisotropic\$4 with (coat\$3 or deposit\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2004/12/09 11:14			
2	BRS	L2	1463	1 same trench	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2004/12/09 11:15			
3	BRS	L3	505	2 and @pd<="20000323"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2004/12/09 11:15			
4	BRS	L4		anisotropic\$4 adj3 (coat\$3 or deposit\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2004/12/09 11:20			
5	BRS	L5		anisotropic\$4 adj2 (coat\$3 or deposit\$3)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2004/12/09 11:14			
6	BRS	L6		anisotropic\$4 adj (coat\$3 or deposit\$3)		2004/12/09 11:14			
7	BRS	L7 :	57	6 same trench	EPULIPUL I	2004/12/09 11:15			
8	BRS I	_8	17	7 and @pd<="20000323"	(PP)	2004/12/09 13:29			

	Туре	L#	Hits	Search Text	DBs	Time Stamp	Comments	Error Definition	Errors
9	BRS	L9	115	(anisotropic\$4 adj3 (coat\$3 or deposit\$3)) same (dop\$3 or implant\$5)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2004/12/09 11:21			
10	BRS	L10	49	9 and @pd<="20000323"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2004/12/09 13:30			,
11	BRS	L11	1188	dop\$3 with reduc\$4 with (dielectric constant)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2004/12/09 13:29			
12	BRS	L12	421	11 and @pd<="20000323"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2004/12/09 13:30			
13	BRS	L13	293	dop\$3 with reduc\$4 with (dielectric constant) with oxide	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2004/12/09 13:30			
14	BRS	L14	79	13 and @pd<="20000323"	EPI I IPI I	2004/12/09 13:30			
15	BRS	L15	79	14 and @pd<="20000323"		2004/12/09 14:24			
16	BRS I	-16	1	((peroxide or "H.sub.2O.sub.2") with (methylsilane or "CH.sub.3		2004/12/09 14:23			

	Туре	L#	Hits	Search Text	DBs	Time Stamp	Comments	Error Definition	Errors
17	BRS	L18	0	17 and @pd<="20000323"	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2004/12/09 14:24			
18	BRS	L17	40	(trench same fill\$3) and ((peroxide or "H.sub.2O.sub.2") with (methylsilane or "CH.sub.3 SiH.sub.3"))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2004/12/09 15:25			
19	BRS	L19	9	("B" or boron) same ((peroxide or "H.sub.2O.sub.2") with (methylsilane or "CH.sub.3 SiH.sub.3"))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2004/12/09 15:05			
20	BRS	L20	9	methylsilane or "CH sub 3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2004/12/09 15:05			
21	BRS	L21	1	"H.sub.2O.sub.2") with (methylsilane or "CH.sub.3	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	2004/12/09 15:26			